



etherea  
light-source solutions





ipl-sq

EPK  
13.03.09  
antes

EPK  
10.08.09  
antes 19

filtro 640 nm, 16 J/cm<sup>2</sup>, 30 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



filtro 640 nm, 17 J/cm<sup>2</sup>, 30 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES





filtro 640 nm, 17 J/cm<sup>2</sup>, 30 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



filtro 640 nm, 16 J/cm<sup>2</sup>, 30 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



filtro 640 nm, 17 J/cm<sup>2</sup>, 20 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES





filtro 640 nm, 16 J/cm<sup>2</sup>, 30 ms

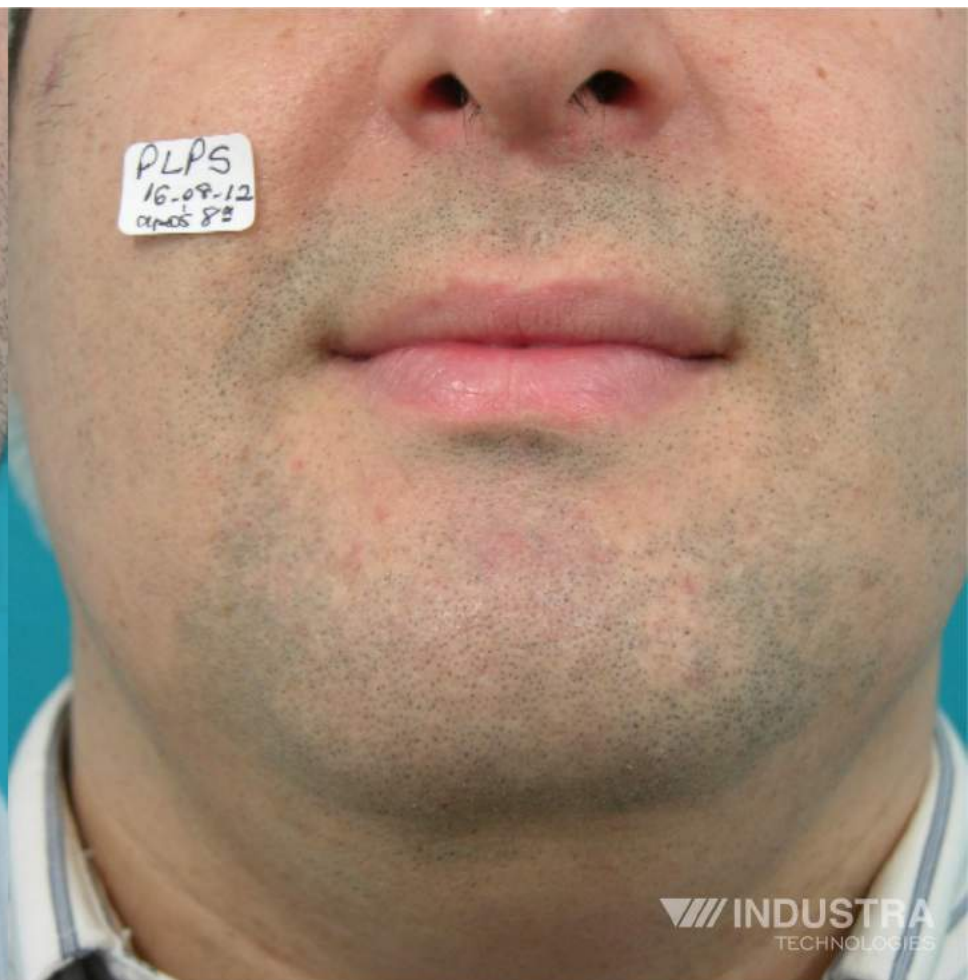
CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES







**INDUSTRA**  
TECHNOLOGIES



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TECHNOLOGIES









filtro 540 nm, 18 J/cm<sup>2</sup>, 15 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



SAM  
25-06-09  
antes

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TECHNOLOGIES



SAM  
21-07-09  
depois

INDUSTRA  
TECHNOLOGIES

filtro 540 nm, 19 J/cm<sup>2</sup>, 15 ms

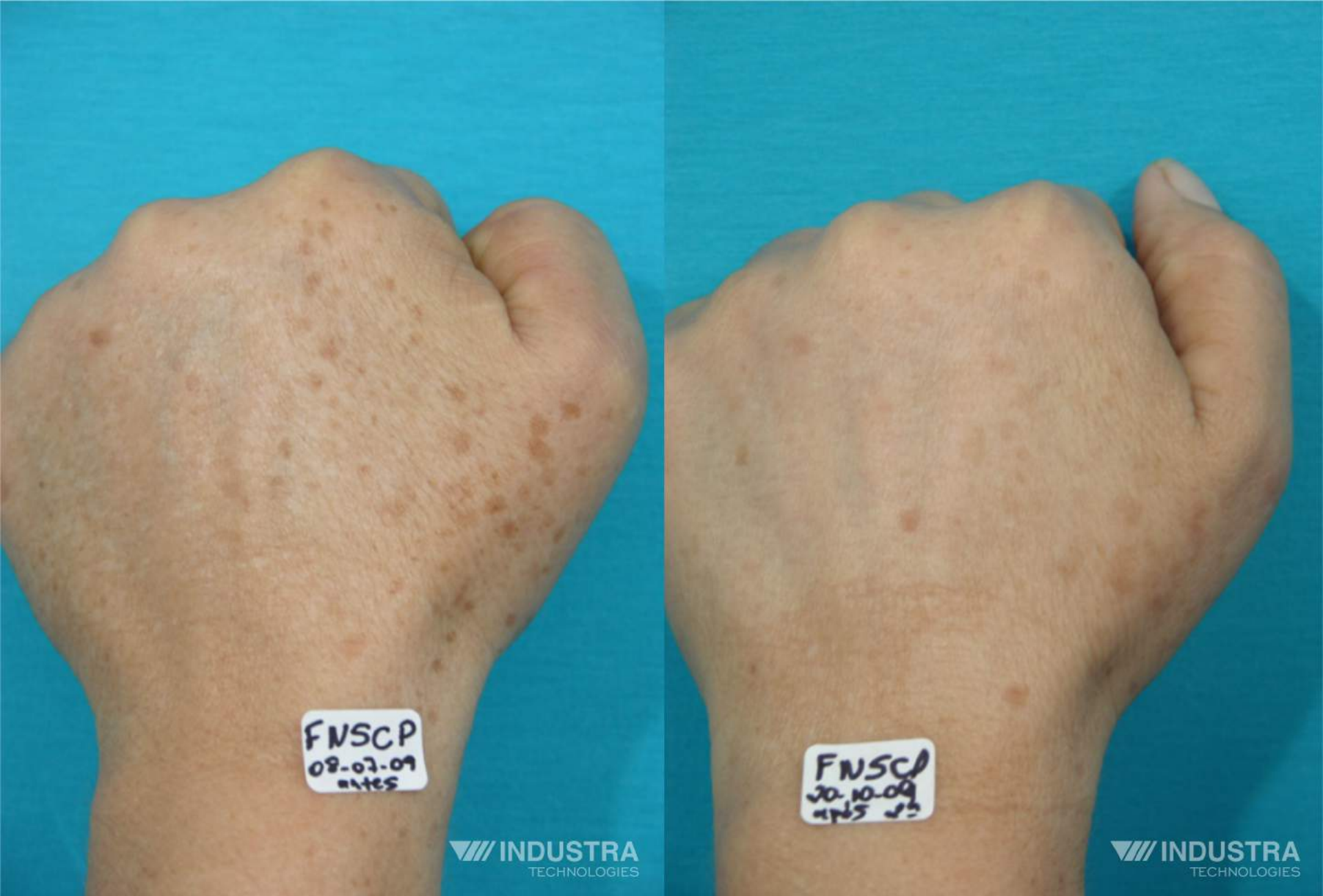
CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



filtro 540 nm, 18 J/cm<sup>2</sup>, 15 ms

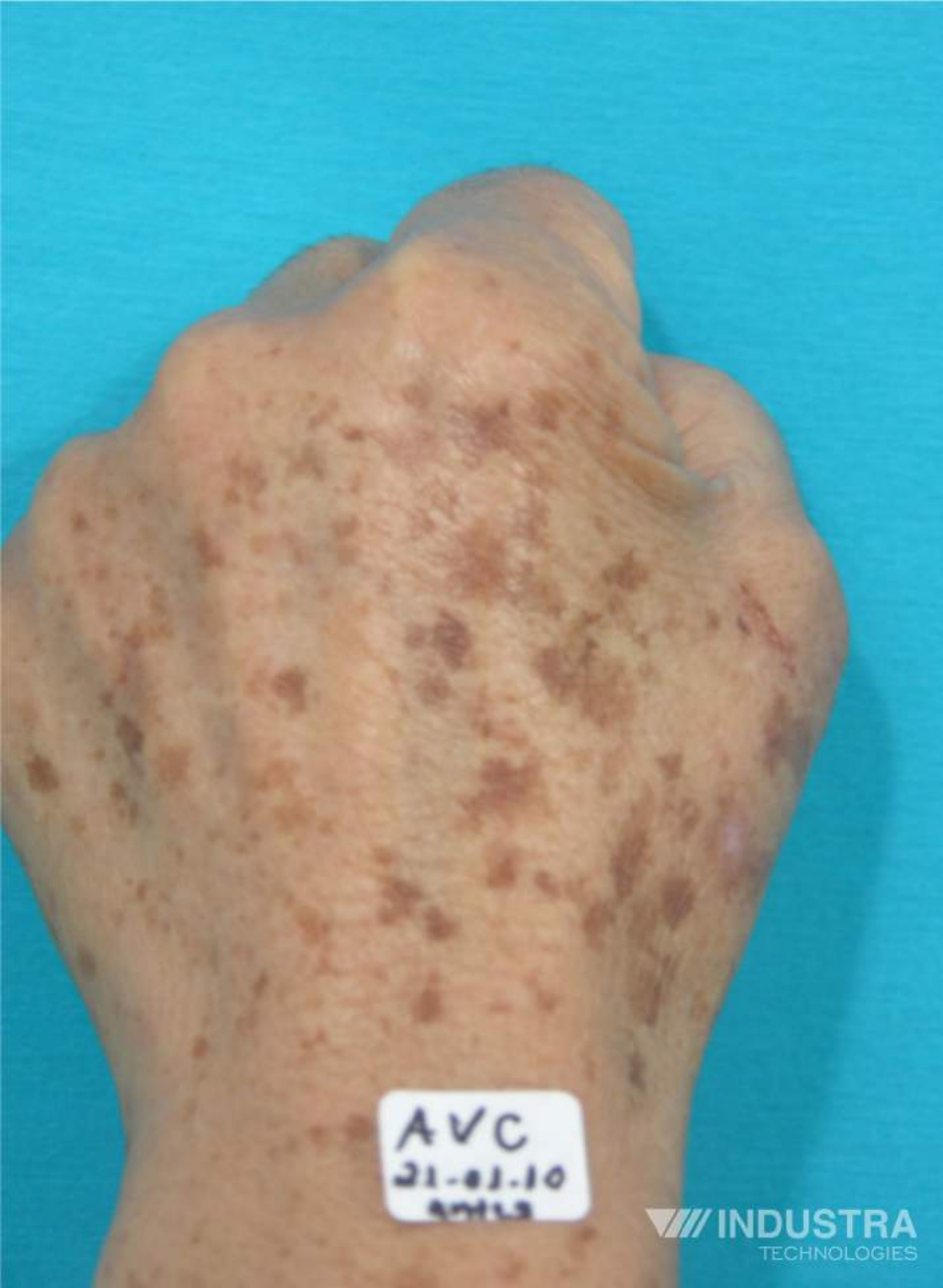
CENTRO DE TREINAMENTOS- INDUSTRA TECHNOLOGIES





filtro 540 nm, 18 J/cm<sup>2</sup>, 15 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



filtro 540 nm, 15 J/cm<sup>2</sup>, 15 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES







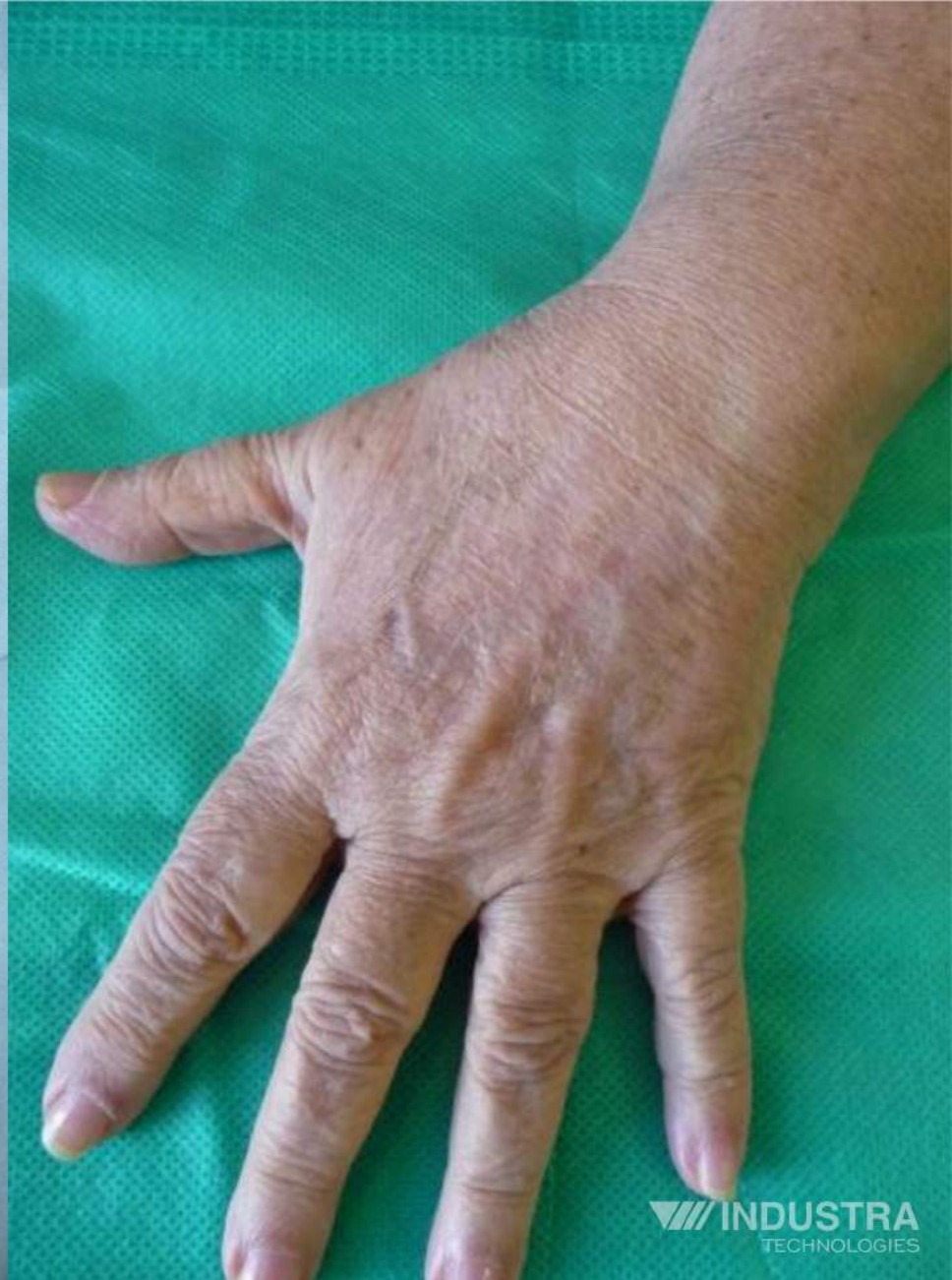




filtro 540 nm, 20 J/cm<sup>2</sup>, 15 ms

**CORTESIA:** Marcio Serra. Rio de Janeiro, RJ. Brasil.





filtro 540 nm, 20 J/cm<sup>2</sup>, 15 ms

**CORTESIA:** Marcio Serra. Rio de Janeiro, RJ. Brasil





filtro 540 nm, 15 J/cm<sup>2</sup>, 15 ms

**CORTESIA:** Maisa Pamponet. Salvador, BA. Brasil



filtro 540 nm, 15 J/cm<sup>2</sup>, 15 ms

**CORTESIA:** Maisa Pamponet. Salvador, BA. Brasil





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**CORTESIA:** Flávia Ramos. Campo dos Goytacazes, RJ. Brasil.

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filtro 540 nm, 16 J/cm<sup>2</sup>, 15 ms

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filtro 540 nm, 20 J/cm<sup>2</sup>, 15 ms

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filtro 540 nm, 17 J/cm<sup>2</sup>, 10 ms



filtro 540 nm, 15 J/cm<sup>2</sup>, 20 ms

**CORTESIA:** Lilian Braga. Sorocaba, SP. Brasil.

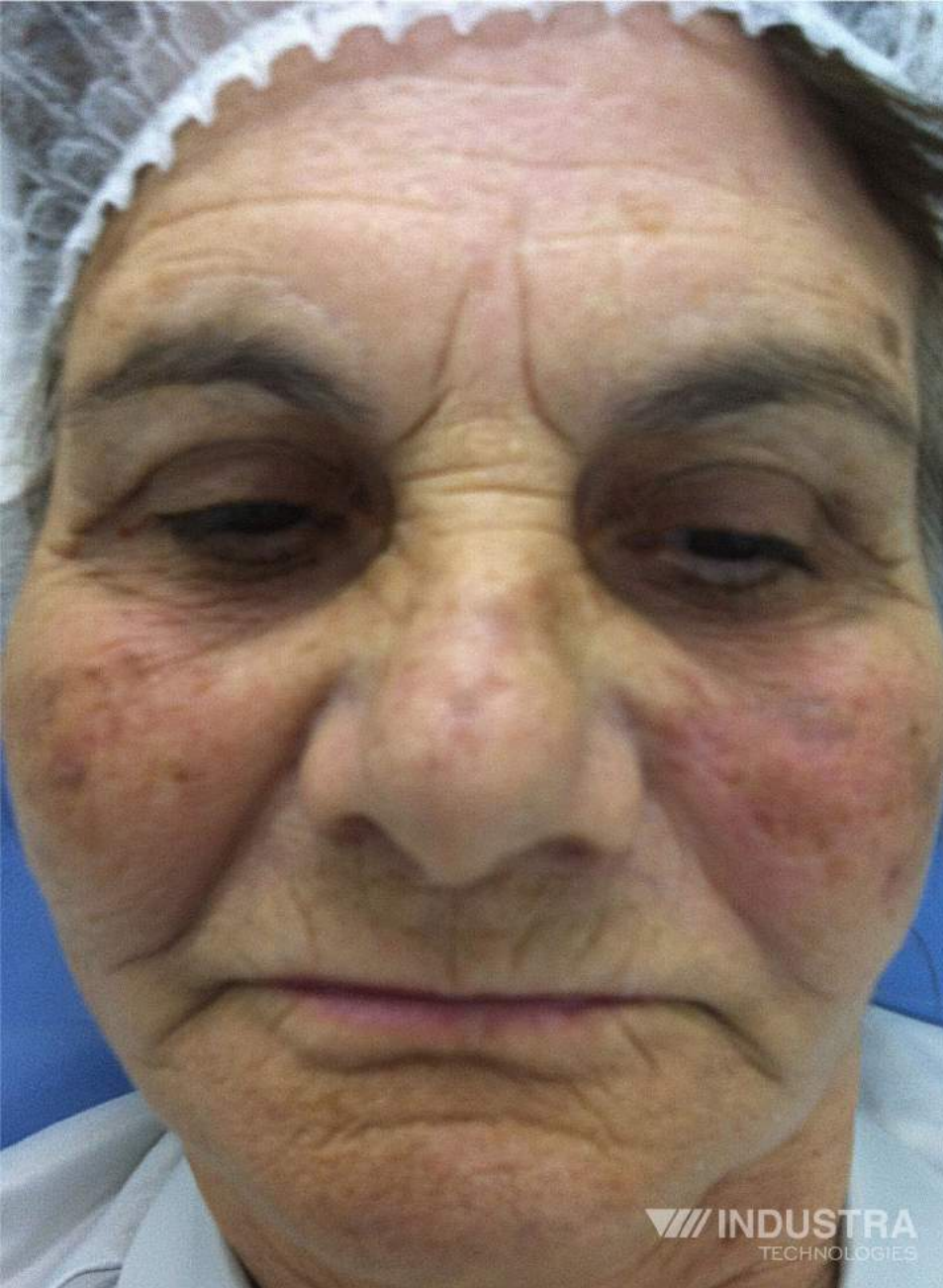




filtro 540 nm, 14/15 J/cm<sup>2</sup>, 15 ms

**CORTESIA:** Fernando Mandelli. Blumenau, SC. Brasil.

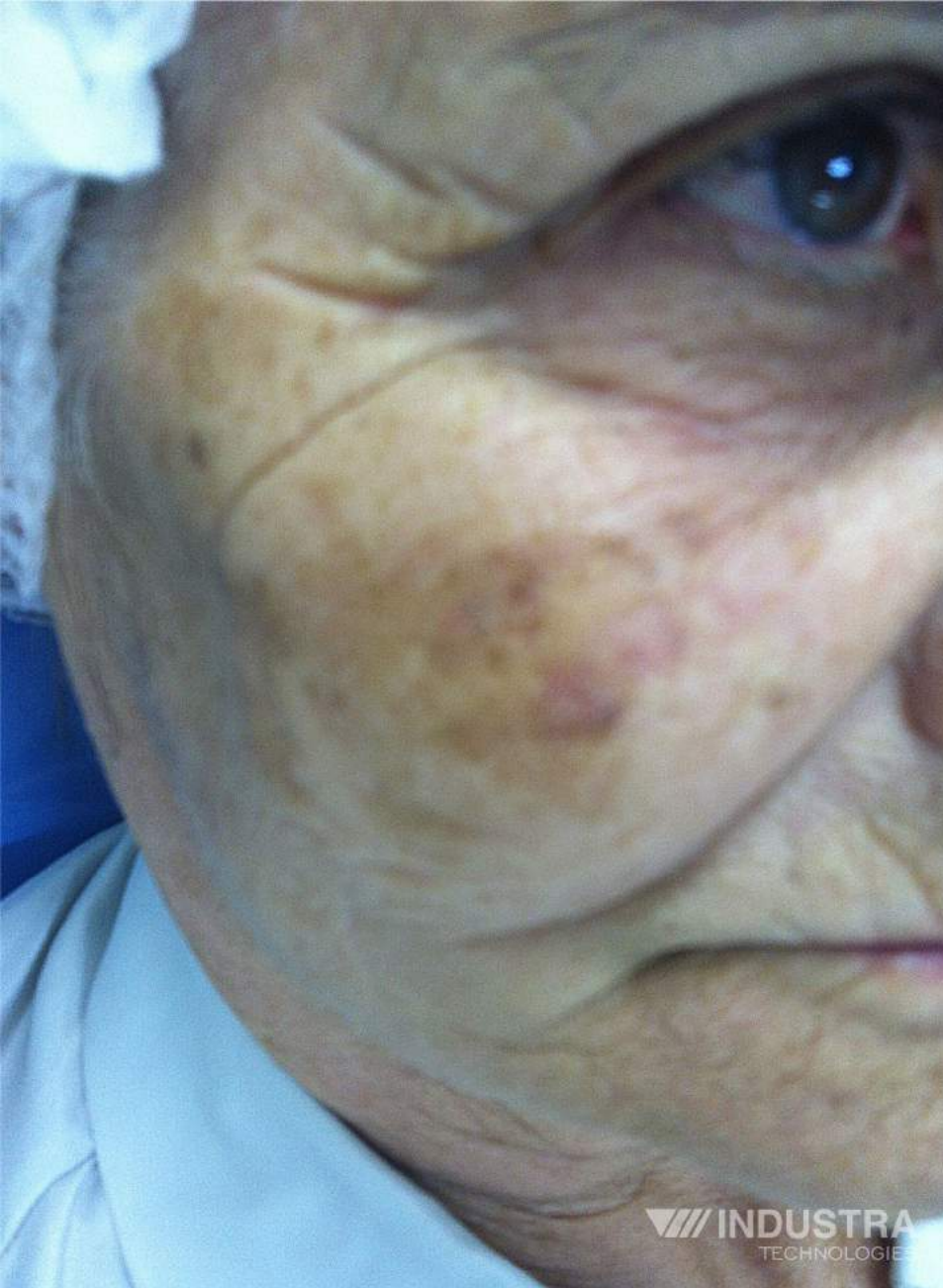




filtro 540 nm, 14/15 J/cm<sup>2</sup>, 15 ms

**CORTESIA:** Fernando Mandelli. Blumenau, SC





filtro 540 nm, 14/15 J/cm<sup>2</sup>, 15 ms

**CORTESIA:** Fernando Mandelli. Blumenau, SC. Brasil.





filtro 540 nm, 14 J/cm<sup>2</sup>, 15 ms

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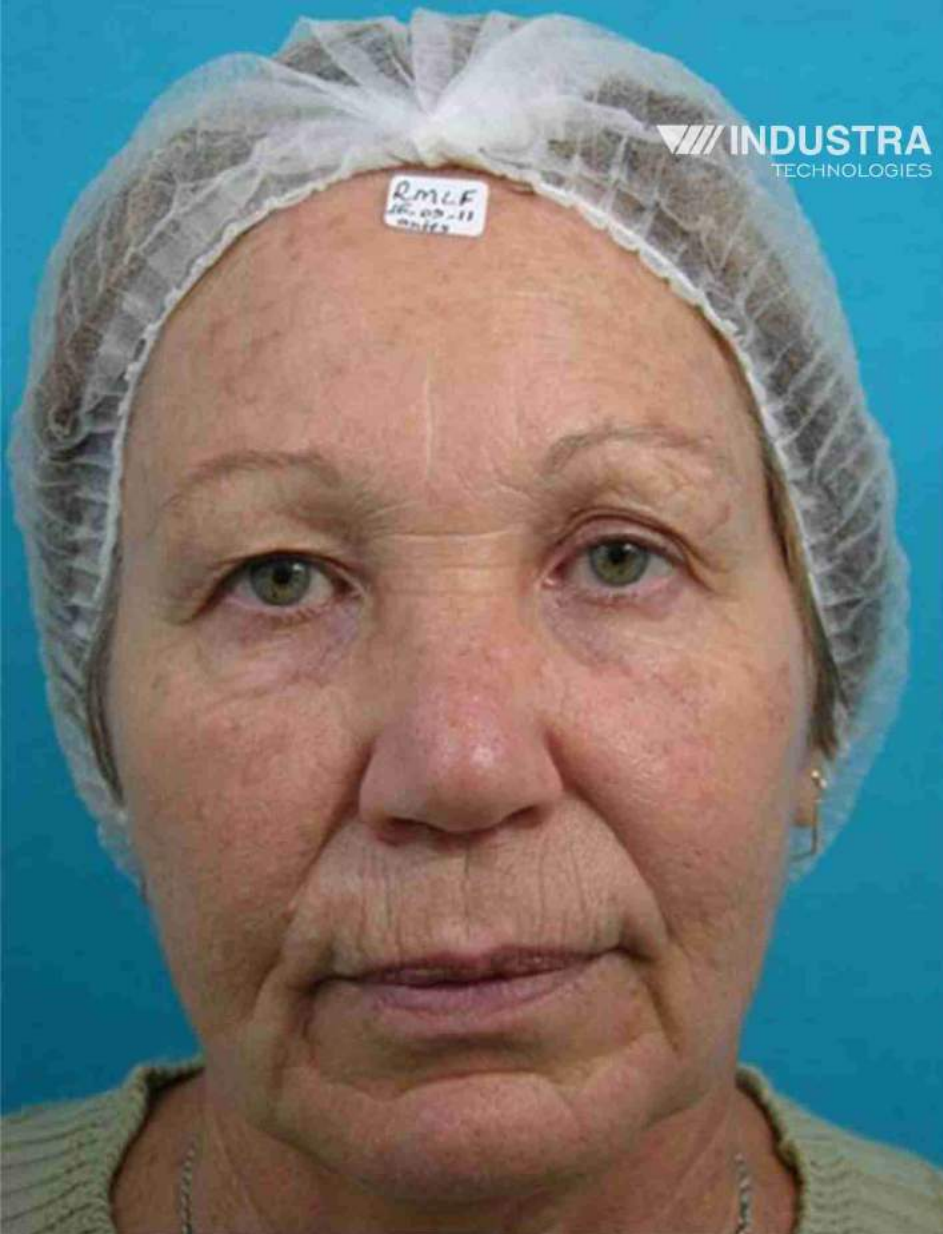
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filtro 540 nm, 14 J/cm<sup>2</sup>, 15 ms

CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES







filtro 540 nm, 14 J/cm<sup>2</sup>, 15 ms, AR5%; filtro 640 nm, 12 J/cm<sup>2</sup>, 40 ms  
filtro 540 nm, 15 J/cm<sup>2</sup>, 15 ms, AR5%; filtro 640 nm, 12 J/cm<sup>2</sup>, 30 ms + VT 540 nm, 18 J/cm<sup>2</sup>, 15 ms, AR 5%  
CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



filtro 540 nm, 14 J/cm<sup>2</sup>, 15 ms, AR5%; filtro 640 nm, 12 J/cm<sup>2</sup>, 40 ms

filtro 540 nm, 15 J/cm<sup>2</sup>, 15 ms, AR5%; filtro 640 nm, 12 J/cm<sup>2</sup>, 30 ms + VT 540 nm, 18 J/cm<sup>2</sup>, 15 ms, AR 5%

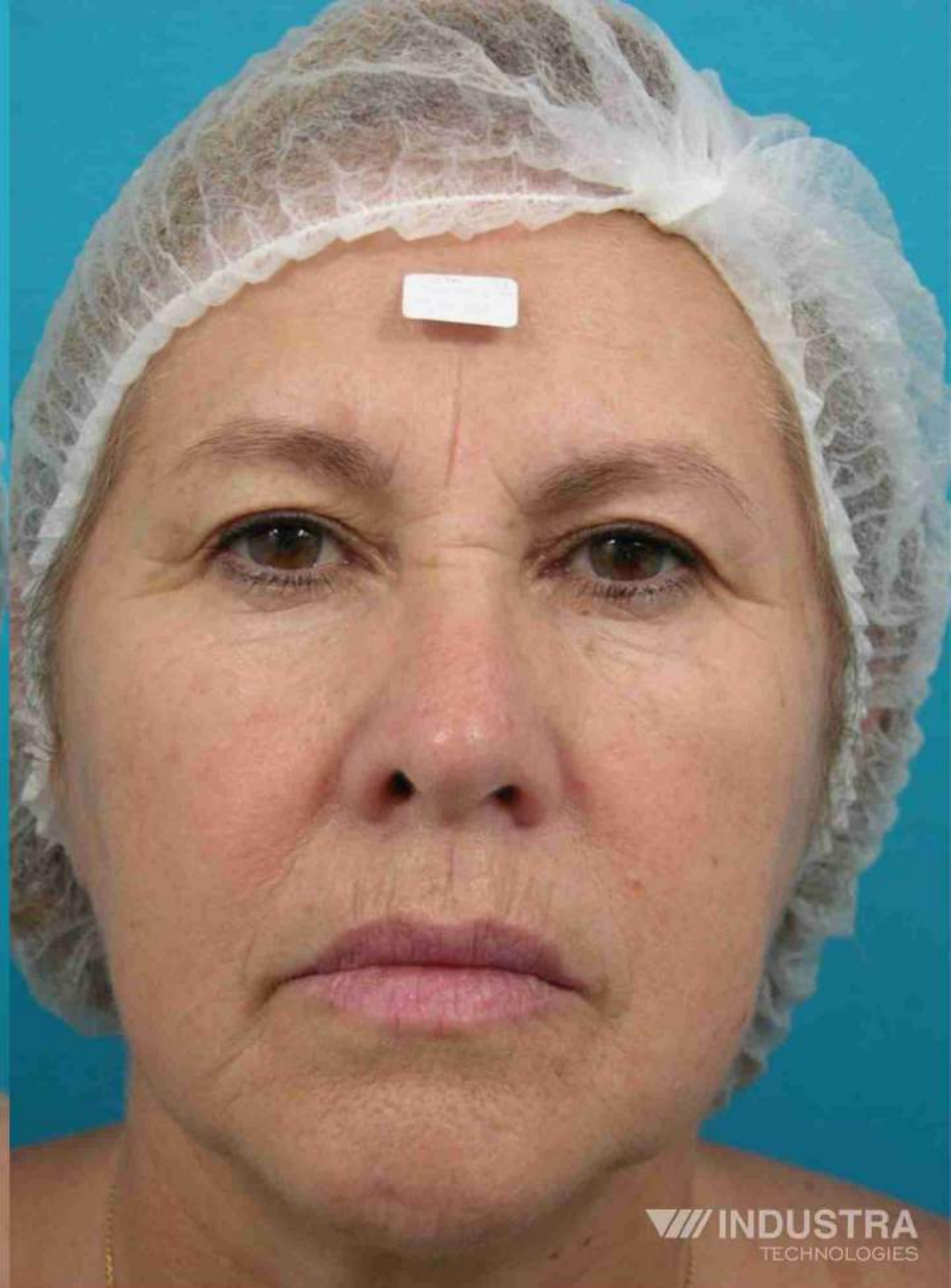
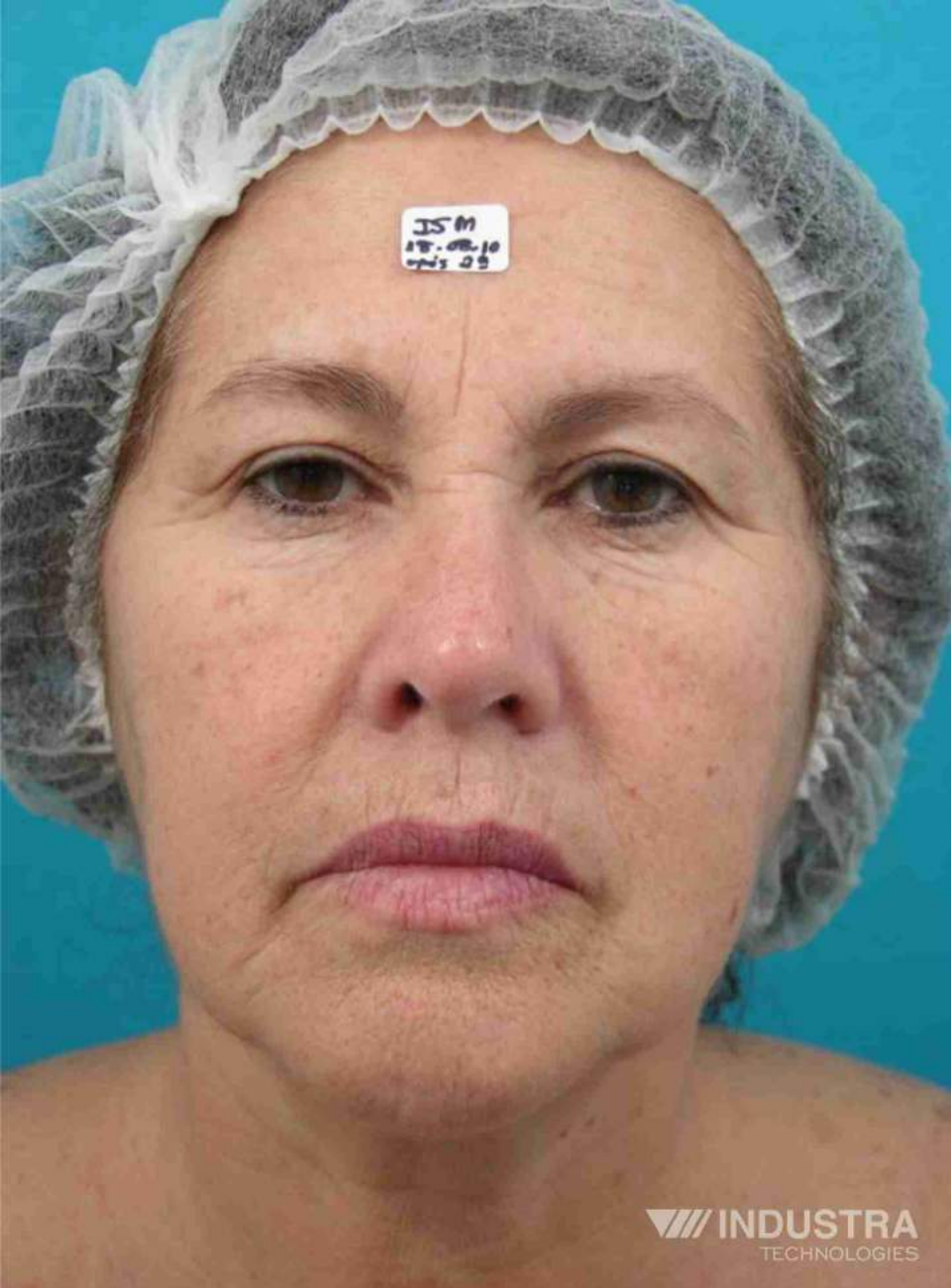
CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES





filtro 640 nm, 12 J/cm<sup>2</sup>, 30 ms + VT, 18 J/cm<sup>2</sup>, 15 ms, AR 5%  
CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES







filtro 640 nm, 12 J/cm<sup>2</sup>, 100 ms; filtro 400 nm, 10 J/cm<sup>2</sup>, 30 ms  
CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES





filtro 640 nm, 12 J/cm<sup>2</sup>, 100 ms; filtro 400 nm, 10 J/cm<sup>2</sup>, 30 ms  
CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



filtro 640 nm, 12 J/cm<sup>2</sup>, 100 ms; filtro 400 nm, 8 J/cm<sup>2</sup>, 30 ms  
CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES





filtro 640 nm, 12 J/cm<sup>2</sup>, 100 ms; filtro 400 nm, 8 J/cm<sup>2</sup>, 30 ms  
CENTRO DE TREINAMENTOS – INDUSTRA TECHNOLOGIES



filtro 540 nm, 15 J/cm<sup>2</sup>, 15 ms; filtro 540 nm, 10 J/cm<sup>2</sup>, 20 ms; filtro 540 nm, 14 J/cm<sup>2</sup>, 10 ms

**CORTESIA:** Carlos Alberto Ferreira Jorge. Campinas, SP. Brasil.





filtro 540 nm, 15 J/cm<sup>2</sup>, 15 ms; filtro 540 nm, 10 J/cm<sup>2</sup>, 20 ms; filtro 540 nm, 14 J/cm<sup>2</sup>, 10 ms

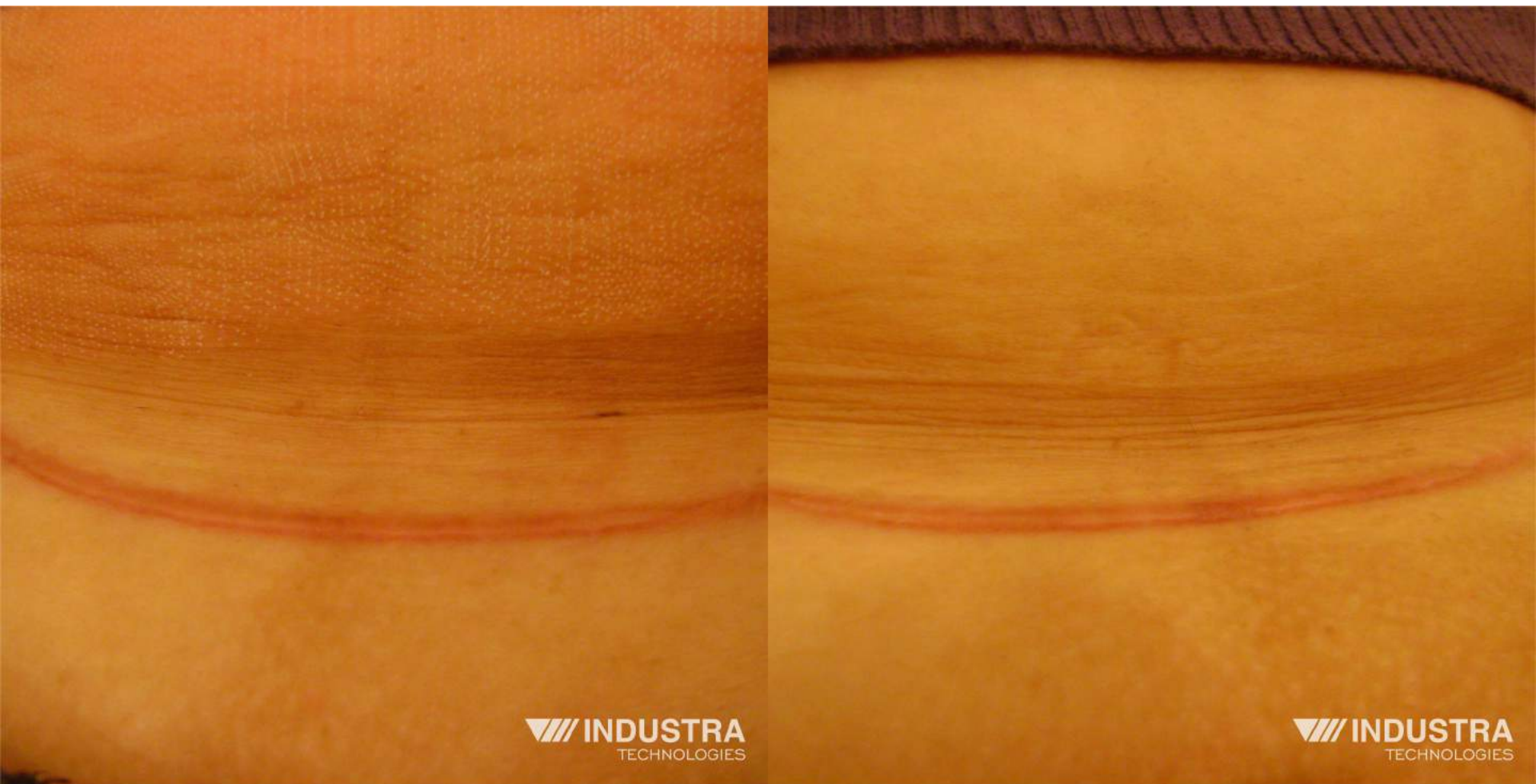
**CORTESIA:** Carlos Alberto Ferreira Jorge. Campinas, SP. Brasil.



filtro 540 nm, 15 J/cm<sup>2</sup>, 30 ms; filtro 540 nm, 14 J/cm<sup>2</sup>, 15 ms; filtro 540 nm, 16 J/cm<sup>2</sup>, 30 ms;

**CORTESIA:** Fabiana Wanick. Niterói, RJ. Brasil.





filtro 540 nm, 14 J/cm<sup>2</sup>, 10 ms

**CORTESIA:** Sumaya Mattar. Juiz de Fora, MG



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